

Refine Search

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L16 and basic	18

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<u>L19</u>	116 and basic	18	<u>L19</u>
<u>L18</u>	117 and (base or basic)	2	<u>L18</u>
<u>L17</u>	L16 and (cellulose or water soluble (polymer or polymeric) or polysaccharide)	3	<u>L17</u>
<u>L16</u>	114 or 115	21	<u>L16</u>

L15 (quaternary adj ammonium adj (salt or hydroxide) or tetramethylammonium hydroxide or tetraethylammonium hydroxide or tetrapropylammonium hydroxide or tetraisopropylammonium hydroxide or tetrabutylammonium hydroxide or tetraisobutylammonium hydroxide or tetramethyl ammonium hydroxide or tetraethyl ammonium hydroxide or tetrapropyl ammonium hydroxide or tetraisopropyl ammonium hydroxide or tetra butyl ammonium hydroxide or tetraisobutyl ammonium hydroxide or tetra methyl ammonium hydroxide or tetra ethyl ammonium hydroxide or tetra propyl ammonium hydroxide or tetra isopropyl ammonium hydroxide or tetra butyl ammonium hydroxide or tetra isobutyl ammonium hydroxide or tmah) and inorganic adj acid near20 salt and

9 L15

	(amorphous silicon or polysilicon) same (film or layer or substrate) and (silicon nitride or "si.sub.3 n.sub.4" or si3n4) same (film or layer or substrate)	
	(quaternary adj ammonium adj (salt or hydroxide) or tetramethylammonium hydroxide or tetraethylammonium hydroxide or tetrapropylammonium hydroxide or tetraisopropylammonium hydroxide or tetrabutylammonium hydroxide or tetraisobutylammonium hydroxide or tetramethyl ammonium hydroxide or tetraethyl ammonium hydroxide or tetrapropyl ammonium hydroxide or tetraisopropyl ammonium hydroxide or tetra butyl ammonium hydroxide or tetraisobutyl ammonium hydroxide or tetra methyl ammonium hydroxide or tetra ethyl ammonium hydroxide or tetra propyl ammonium hydroxide or tetra isopropyl ammonium hydroxide or tetra butyl ammonium hydroxide or tetra isobutyl ammonium hydroxide or tmah) and inorganic adj acid near20 salt and (amorphous silicon or polysilicon) same (film or layer or substrate) and (silicon oxide or silicon dioxide or "sio.sub.2" or sio2) same (film or layer or substrate)	
<u>L14</u>	L10 and (cellulose or water soluble (polymer or polymeric) or polysaccharide)	21 <u>L14</u>
<u>L13</u>	L9 and (cellulose or water soluble (polymer or polymeric) or polysaccharide)	2 <u>L13</u>
<u>L12</u>	L9 and (cellulose or water soluble (polymer or polymeric) or polysaccharide)	2 <u>L12</u>
<u>L11</u>	L9 and (cellulose or water soluble polyme\$ or polysaccharide)	2 <u>L11</u>
	(quaternary adj ammonium adj (salt or hydroxide) or tetramethylammonium hydroxide or tetraethylammonium hydroxide or tetrapropylammonium hydroxide or tetraisopropylammonium hydroxide or tetrabutylammonium hydroxide or tetraisobutylammonium hydroxide or tetramethyl ammonium hydroxide or tetraethyl ammonium hydroxide or tetrapropyl ammonium hydroxide or tetraisopropyl ammonium hydroxide or tetra butyl ammonium hydroxide or tetraisobutyl ammonium hydroxide or tetra methyl ammonium hydroxide or tetra ethyl ammonium hydroxide or tetra propyl ammonium hydroxide or tetra isopropyl ammonium hydroxide or tetra butyl ammonium hydroxide or tetra isobutyl ammonium hydroxide or tmah) and inorganic adj acid near20 salt and polysilicon same (film or layer or substrate) and (silicon nitride or "si.sub.3 n.sub.4" or si3n4) same (film or layer or substrate)	
<u>L10</u>	(quaternary adj ammonium adj (salt or hydroxide) or tetramethylammonium hydroxide or tetraethylammonium hydroxide or tetrapropylammonium hydroxide or tetraisopropylammonium hydroxide or tetrabutylammonium hydroxide or tetraisobutylammonium hydroxide or tetramethyl ammonium hydroxide or tetraethyl ammonium hydroxide or tetrapropyl ammonium hydroxide or tetraisopropyl ammonium hydroxide or tetra butyl ammonium hydroxide or tetraisobutyl ammonium hydroxide or tetra methyl ammonium hydroxide or tetra ethyl ammonium hydroxide or tetra propyl ammonium hydroxide or tetra isopropyl ammonium hydroxide or tetra butyl ammonium hydroxide or tetra isobutyl ammonium hydroxide or tmah) and inorganic adj acid near20 salt and polysilicon same (film or layer or substrate) and (silicon nitride or "si.sub.3 n.sub.4" or si3n4) same (film or layer or substrate)	8 <u>L10</u>
	(quaternary adj ammonium adj (salt or hydroxide) or tetramethylammonium hydroxide or tetraethylammonium hydroxide or tetrapropylammonium hydroxide or tetraisopropylammonium hydroxide or tetrabutylammonium hydroxide or tetraisobutylammonium hydroxide or tetramethyl ammonium hydroxide or tetraethyl ammonium hydroxide or tetrapropyl ammonium hydroxide or tetraisopropyl ammonium hydroxide or tetra butyl ammonium hydroxide or tetraisobutyl ammonium hydroxide or tetra methyl ammonium hydroxide or tetra ethyl ammonium hydroxide or tetra propyl ammonium hydroxide or tetra isopropyl ammonium hydroxide or tetra butyl ammonium hydroxide or tetra isobutyl ammonium hydroxide or tmah) and inorganic adj acid near20 salt and polysilicon same (film or layer or substrate) and (silicon oxide or silicon dioxide or "sio.sub.2" or sio2) same (film or layer or substrate)	
<u>L9</u>	L1 and other	19 <u>L9</u>
<u>L8</u>	L1 and basic with quaternary	0 <u>L8</u>
<u>L7</u>	(quaternary adj ammonium adj (salt or hydroxide) or tetramethylammonium hydroxide or tetraethylammonium hydroxide or tetrapropylammonium hydroxide or tetraisopropylammonium hydroxide or tetrabutylammonium hydroxide or tetraisobutylammonium hydroxide or tetramethyl ammonium hydroxide or tetraethyl ammonium hydroxide or tetrapropyl ammonium hydroxide or tetraisopropyl ammonium hydroxide or tetra butyl ammonium hydroxide or	1 <u>L7</u>
<u>L6</u>		24 <u>L6</u>

tetraisobutyl ammonium hydroxide or tetra methyl ammonium hydroxide or tetra ethyl ammonium hydroxide or tetra propyl ammonium hydroxide or tetra isopropyl ammonium hydroxide or tetra butyl ammonium hydroxide or tetra isobutyl ammonium hydroxide or tmah) and inorganic adj acid near20 salt and (polysilicon or amorphous silicon) same (film or layer or substrate)

DB=PGPB,USPT; PLUR=YES; OP=ADJ

<u>L5</u>	(quaternary adj ammonium adj (salt or hydroxide) or tetra methyl ammonium hydroxide or tetra ethyl ammonium hydroxide or tetra propyl ammonium hydroxide or tetra isopropyl ammonium hydroxide or tetra butyl ammonium hydroxide or tetra isobutyl ammonium hydroxide or tmah) and inorganic adj acid near20 salt and (polysilicon or amorphous silicon) same (film or layer or substrate)	14	<u>L5</u>
<u>L4</u>	L3 and (quaternary adj ammonium adj (salt or hydroxide) or tetramethylammonium hydroxide or tetraethylammonium hydroxide or tetrapropylammonium hydroxide or tetraisopropylammonium hydroxide or tetrabutylammonium hydroxide or tetraisobutylammonium hydroxide or tmah) and inorganic adj acid near20 salt	0	<u>L4</u>
<u>L3</u>	6354913.pn. or 4588421.pn.	2	<u>L3</u>
<u>L2</u>	L1 and amorphous silicon with silicon oxide	1	<u>L2</u>
<u>L1</u>	20040132305	1	<u>L1</u>

END OF SEARCH HISTORY